# Translation





# **PCT**

# INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY (Chapter II of the Patent Cooperation Treaty)

(PCT Article 36 and Rule 70)

A == 1					
Applicant's or agent's file reference PC-9015	FOR FURTHER ACTIO	N	See Form PCT/IPEA/416		
International application No.	International filing date (da	y/month/year)	Priority date (day/month/year)		
PCT/JP2003/015427 02 December 2		02.12.2003)	02 December 2002 (02.12.2002)		
International Patent Classification (IPC) or n G03F 7/40, H01L 21/027	ational classification and IPC	;			
Applicant		<del> </del>			
	TOKYO OHKA KOGYO CO., LTD.				
This report is the international prelir Authority under Article 35 and trans	ninary examination report, es mitted to the applicant accor	stablished by this ding to Article 3	International Preliminary Examining 6.		
2. This REPORT consists of a total of	6 sheets, inclu	ding this cover s	cheet.		
3. This report is also accompanied by A	ANNEXES, comprising:				
a. (sent to the applicant and	a. (sent to the applicant and to the International Bureau) a total of sheets, as follows:				
sheets of the description, claims and/or drawings which have been amended and are the basis of this report and/or sheets containing rectifications authorized by this Authority (see Rule 70.16 and Section 607 of the Administrative Instructions).					
sheets which supe beyond the disclo Supplemental Box	sure in the international appl	ch this Authority lication as filed,	considers contain an amendment that goes as indicated in item 4 of Box No. I and the		
b. (sent to the International Bureau only) a total of (indicate type and number of electronic carrier(s))  readable form only, as indicated in the Supplemental Box Relating to Sequence Listing (see Section 802 of the Administrative Instructions).					
4. This report contains indications relating to the following items:					
Box No. I Basis of the report					
Box No. II Priority					
Box No. III Non-establishment of opinion with regard to novelty, inventive step and industrial applicability					
Box No. IV Lack of unity of invention					
Box No. V  Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement					
Box No. VI Certain documents cited					
Box No. VII Certain defects in the international application					
Box No. VIII Certain observations on the international application					
Date of submission of the demand		of completion o	of this report		
27 May 2004 (27.05.2		06 October 2004 (06.10.2004)			
Name and mailing address of the IPEA/JP	Auth	Authorized officer			
Facsimile No.	Tele	phone No.			



## INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

International application No. PCT/JP2003/015427

Box No.	I	Basis of the report			
		d to the language, this report is based on the international application in the languaged under this item.	uage in which it was filed, unless		
	This which	s report is based on translations from the original language into the following ch is language of a translation furnished for the purpose of:	language,		
		international search (under Rules 12.3 and 23.1(b))			
		publication of the international application (under Rule 12.4)			
		international preliminary examination (under Rules 55.2 and/or 55.3)			
furnis	hed to	rd to the elements of the international application, this report is based on (in the receiving Office in response to an invitation under Article 14 are referred to this report):  international application as originally filed/furnished	replacement sheets which have been I to in this report as "originally filed"		
		description:			
-	page	•	, as originally filed/furnished		
	page		, as originally modification		
	page	<del></del>			
	the c	elaims:			
	page		, as originally filed/furnished		
	page		ther with any statement) under Article 19		
	page				
	page				
	the d	lrawings:			
	page		, as originally filed/furnished		
1	page		,,,		
ł	page	received by this Authority on			
	a seo	quence listing and/or any related table(s) - see Supplemental Box Relating to Seq	mence Listing.		
1			, <i>G</i>		
3.	The	amendments have resulted in the cancellation of:			
3. []					
	H	the description, pages			
Į	$\mathbb{H}$	the claims, Nos.			
	$\vdash$	the drawings, sheets/figs			
		the sequence listing (specify):			
	Ш	any table(s) related to sequence listing (specify):			
4.	made	report has been established as if (some of) the amendments annexed to this ree, since they have been considered to go beyond the disclosure as filed, as it e 70.2(c)).			
1		the description, pages			
		the claims, Nos.			
ł		the drawings, sheets/figs			
Ì		the sequence listing (specify):	•		
		any table(s) related to sequence listing (specify):			
* If iten	n 4 ap	oplies, some or all of those sheets may be marked "superseded."			



nemational application No.
PCT/JP03/15427

. Statement			
Novelty (N)	Claims	1-8	YES
	Claims	9, 10	NO
Inventive step (IS)	Claims		YES
	Claims	1-10	МО
Industrial applicability (IA)	Claims	1-10	YES
	Claims		NO

2. Citations and explanations (Rule 70.7)

Document 1: JP, 5-315241, A (K.K. Sorutekku), 26 November, 1993 (26.11.93), claim 1, paragraphs [0022]-

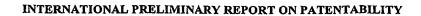
Document 2: JP, 2002-299223, A (Matsushita Electric Industrial Co., Ltd.), 11 October, 2002 (11.10.02), paragraphs [0014] and [0028]-[0044]

Document 3: JP, 2000-338674, A (Fuji Photo Film Co., Ltd.), 8 December, 2000 (08.12.00), claim 1, paragraphs [0131]-[0134]

Document 4: JP, 9-82629, A (K.K. Sorutekku), 28 March, 1997 (28.03.97), claim 1, paragraph [0019] Document 5: JP, 7-226358, A (Hitachi, Ltd.), 22 August, 1995 (22.08.95), the claims

The subject matters of claims 1 and 6-8 do not appear to involve an inventive step in view of documents 1-3. Document 1 describes a resist pattern forming method wherein, in a rinsing process in the development of a resist pattern, a substituent liquid for a rinsing liquid is made into a critical state in the drying. Documents 2 and 3 describe a positive resist composition having a less than 20 mol% content of alkali soluble units and an acid-dissociation solution suppressing group, and containing a resin component (A) whose alkali solubility increases due to the effect of an acid, an acid producer component (B) to produce an acid by exposure to light, and an organic solvent (C) to dissolve the components (A) and (B). A person skilled in the art could have easily used the positive resist composition taught in documents 2 and 3 in the resist pattern forming method described in document 1.

The subject matters of claims 2, 4 and 5 do not appear to involve an inventive step in view of documents 1-5. Documents 4 and 5 describe an invention wherein water rinsing is performed after the alkali development and then the substitution by a fluorine-inactive liquid is performed. A person skilled in the art could have easily adopted the inventions taught in documents 4 and 5 for the resist pattern forming method described in document 1.



## Box No. VI Certain documents cited

1.	Certain ·	published	documents	Rule	70.10	١
••	OO1 00 111	Published	documents.	11/410	,	,

Application No. Patent No.	Publication date (day/month/year)	Filing date (day/month/year)	Priority date (valid claim) (day/month/year)
JP 2003-243352 A [E, X]	29.08.2003	23.04.2002	10.12.2001
JP 2003-142368 A [E, X]	16.05.2003	31.10.2001	
JP 2003-337406 A [E, X]	28.11.2003	22.05.2002	
JP 2003-92240 A [E, X]	28.03.2003	18.09.2001	

2. N	on-written	disclosures	(Rule 70.9)
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Kind of non-written disclosure

Date of non-written disclosure (day/month/year)

Date of written disclosure referring to non-written disclosure (day/month/year)





Box No. VIII Certain observations on the international application

The following observations on the clarity of the claims, description, and drawings or on the question whether the claims are fully supported by the description, are made:

The disclosure of the specification in the sense of PCT Article 5 is only a resist pattern forming method wherein (1) water rinsing is performed after the alkali development, (2) then the liquid present on the board is replaced with a first fluorine inactive liquid, (3) then the said liquid present on the board is replaced with a second fluorine-inactive liquid containing a surfactant, (4) then the replacing liquid is replaced with a critical drying liquid, and (5) a drying process wherein the said critical drying liquid is dried through a critical state is performed.

Accordingly, the subject matters of claims 1-10 are not supported by the disclosure of the specification in the sense of PCT Article 6.



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In case the space in any of the preceding boxes is not sufficient. Continuation of:  $\boldsymbol{V}$ 

The subject matter of claim 3 does not appear to involve an inventive step in view of documents 1-4. Document 4 describes that a rinsing liquid added with a surfactant is used. A person skilled in the art could have easily adopted the invention taught in document 4 in the invention described in document 1.

The subject matters of claims 9 and 10 do not appear to be novel in view of document 2. Document 2 describes a resist pattern having a high aspect ratio with a thickness of  $0.4 \mu m$ , and a line width of  $0.11 \mu m$  or  $0.10 \mu m$ . The subject matters of claims 9 and 10 as a resist pattern are the same as the invention described in document 2.